



assumed that the dielectric slab with thickness  $d_2$  is uniformly extended throughout the waveguide, and also the current strip is infinitely thin in the  $y$  direction and narrow in the transverse direction with respect to the metal strip, so that the current in the  $z$  direction is neglected.

In the spectral-domain technique, the input impedance of the  $E$ -plane transition  $Z_{in}$  seen by the microstrip line is obtained through the self-reaction concept of the following equation:

$$Z_{in} = -\frac{1}{I_{in}^2} \left( \sum_{n=0}^{\infty} \sum_{m=1}^{\infty} \int_0^{\infty} \tilde{E}_x(\alpha, \gamma, \beta) \cdot \tilde{J}_x(\alpha, \gamma, \beta) d\beta \right). \quad (1)$$

The quantities with a tilde ( $\sim$ ) are the Fourier transforms of the corresponding quantities. The product  $\tilde{E}_x(\alpha, \gamma, \beta) \cdot \tilde{J}_x(\alpha, \gamma, \beta)$  represents the power radiated within the confines of the waveguide walls;  $\alpha$ ,  $\gamma$ , and  $\beta$  are the transformation variables of  $x$ ,  $y$ , and  $z$ .  $I_{in}$  is the total input current at the reference plane  $x=0$ .  $\tilde{E}_x(\alpha, \gamma, \beta)$  and  $\tilde{J}_x(\alpha, \gamma, \beta)$  represent the  $x$ -directed electric field and current distribution, respectively.  $\tilde{E}_x(\alpha, \gamma, \beta)$  is derived through the dyadic Green's function  $\tilde{G}_{xx}(\alpha, \gamma, \beta)$  and the current distribution  $\tilde{J}_x(\alpha, \gamma, \beta)$ :

$$\tilde{E}_x(\alpha, \gamma, \beta) = \tilde{G}_{xx}(\alpha, \gamma, \beta) \cdot \tilde{J}_x(\alpha, \gamma, \beta) \quad (2a)$$

where

$$\tilde{G}_{xx}(\alpha, \gamma, \beta) = \frac{\beta^2}{\alpha^2 + \beta^2} Z^e + \frac{\alpha^2}{\alpha^2 + \beta^2} Z^h. \quad (2b)$$

$Z^e$  and  $Z^h$  are the eigenvalue equations of the LSE and LSM modes. Both quantities can be arrived at through the transverse resonance condition, as follows:

$$Z^e = \left( \frac{\hat{Y}_1}{\gamma_1} \coth \gamma_1 d_1 + \frac{\hat{Y}_2}{\gamma_2} \cdot \frac{\frac{\hat{Y}_1}{\gamma_1} \coth \gamma_1 d_1 \coth \gamma_2 d_2 + \frac{\hat{Y}_2}{\gamma_2}}{\frac{\hat{Y}_1}{\gamma_1} \coth \gamma_1 d_1 + \frac{\hat{Y}_2}{\gamma_2} \coth \gamma_2 d_2} \right)^{-1} \quad (3a)$$

$$Z^h = \left( \frac{\gamma_1}{\hat{Z}_1} \coth \gamma_1 d_1 + \frac{\gamma_2}{\hat{Z}_2} \cdot \frac{\frac{\gamma_1}{\hat{Z}_1} \coth \gamma_1 d_1 \coth \gamma_2 d_2 + \frac{\gamma_2}{\hat{Z}_2}}{\frac{\gamma_1}{\hat{Z}_1} \coth \gamma_1 d_1 + \frac{\gamma_2}{\hat{Z}_2} \coth \gamma_2 d_2} \right)^{-1} \quad (3b)$$

Here  $d_1$ ,  $d_2$ ,  $\hat{Y}_1$ ,  $\hat{Y}_2$ ,  $\hat{Z}_1$ , and  $\hat{Z}_2$  are the thickness, admittivity, and impedivity of regions 1 and 2, respectively. The quantities  $\gamma_1$  and  $\gamma_2$  are the propagation constants in the  $y$  direction and can be derived through the characteristic equation

$$\alpha_n^2 + \beta_{mn}^2 = \omega^2 \epsilon_0 \mu_0 \epsilon_r + \gamma_{im}^2, \quad i=1,2 \quad (4)$$

where  $\epsilon_r$  is the relative dielectric constant of region 2,  $\omega$  is the angular frequency, and  $m$  and  $n$  are the mode index numbers.  $\tilde{J}_x(\alpha, \gamma, \beta)$  is obtained through the Fourier transformation of a sinusoidal wave with appropriate applied

boundary conditions [7]. An application of image theory [8] is used to expand  $\tilde{J}_x(\alpha, \gamma, \beta)$  into the final expression:

$$\tilde{J}_x(\alpha, \gamma, \beta) = j \frac{4J_0}{\beta} \sin\left(\frac{m\pi d_3}{b}\right) \sin(\beta z_1) \sin(\beta w) \cdot \frac{k}{k^2 - \alpha^2} (\cos(\alpha x_1) - \cos(kx_1)). \quad (5)$$

Here  $z_1$  is the backshort location, and  $x_1$  and  $w$  are the length and width of the metal strip, respectively.  $J_0$  is the magnitude of the input current,  $k$  is the medium wavenumber, and  $d_3$  is the distance between the metal strip and  $y=0$  in the transverse direction.

Since poles exist in the right-hand side of (3a) and (3b), equation (1) must be further formulated to yield its simplified expression. To evaluate the product  $\tilde{E}_x(\alpha, \gamma, \beta) \cdot \tilde{J}_x(\alpha, \gamma, \beta)$ , the discrete value of  $\beta_{mn}$  must first be determined from the dyadic Green's function  $\tilde{G}_{xx}(\alpha, \gamma, \beta)$ . Once  $\beta_{mn}$  has been obtained, the complex residue theorem can be applied to (1) to compute the input impedance  $Z_{in}$ :

$$Z_{in} = \lim_{\beta \rightarrow \beta_{mn}} (\beta - \beta_{mn}) \left[ \sum_{n=0}^{\infty} \sum_{m=1}^{\infty} -\frac{2j}{\sin^2(kx_1)} \left( \frac{\sin(\beta w)}{\beta w} \right)^2 \cdot \sin(\beta z_1) \sin^2\left(\frac{m\pi d_3}{b}\right) (\cos(\alpha x_1) - \cos(kx_1))^2 \cdot \frac{e^{j\beta z_1}}{a} \left( \frac{k}{k^2 - \alpha^2} \right)^2 \left( \frac{\beta^2}{\alpha^2 + \beta^2} Z^e + \frac{\alpha^2}{\alpha^2 + \beta^2} Z^h \right) \right]. \quad (6)$$

The input  $VSWR$  at the reference plane  $x=0$  is determined as follows:

$$VSWR = \frac{1 + \sqrt{\frac{(R_{in} - Z_0)^2 + X_{in}^2}{(R_{in} + Z_0)^2 + X_{in}^2}}}{1 - \sqrt{\frac{(R_{in} - Z_0)^2 + X_{in}^2}{(R_{in} + Z_0)^2 + X_{in}^2}}}. \quad (7)$$

$Z_0$  is the characteristic impedance of the input microstrip line, and  $R_{in}$  and  $X_{in}$  are the real and imaginary parts of  $Z_{in}$ .

### III. RESULTS

In verifying our calculations, the standard  $Ka$ -band waveguide dimensions are used to compute the input impedance of the transition. The quantities  $d_3$  and  $w$  are fixed at 3.5 mm and 0.187 mm, respectively. The large values of  $m$  and  $n$  are chosen so as to ensure the convergence of the input impedance. Fig. 2 shows the numerical data obtained from the spectral-domain approach and Collin's method [2] for an air-dielectric case ( $\epsilon_r=1.0$ ). The backshort location  $z_1$  and the probe length  $x_1$  are fixed at 2.8 mm and 2.1 mm, respectively. Data computed by the two methods show good agreement in the input impedance of the transition calculated from 27.0 and 40.0 GHz. The input resistance reaches its maximum at approximately 36.0 GHz, and the reactance remains capacitive through-

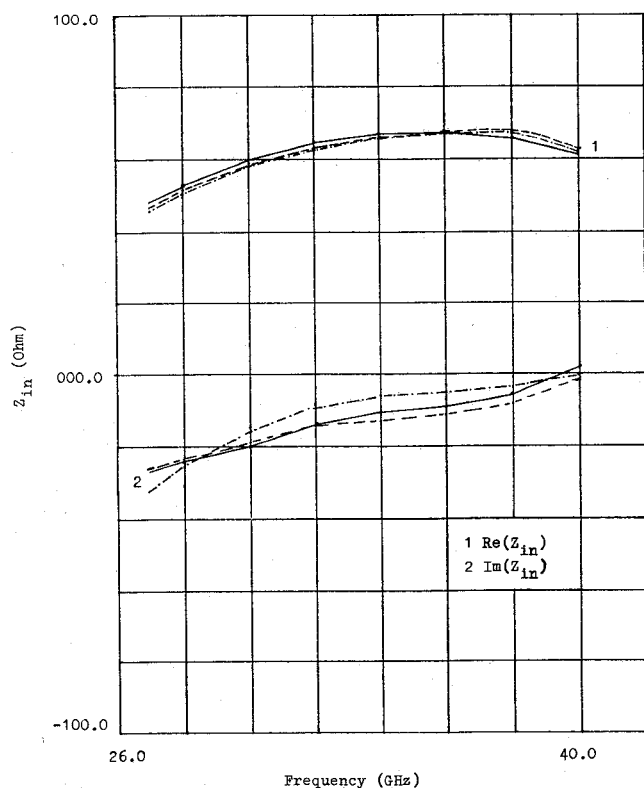


Fig. 2. Input impedance versus frequency. *E*-plane transition with  $x_1 = 2.1$  mm,  $z_1 = 2.8$  mm,  $d_3 = 3.5$  mm,  $w = 0.187$  mm, and  $\epsilon_r = 1.0$ .  
 — Spectral domain technique. ---- Collin's method [2].  
 — Integral equation technique.

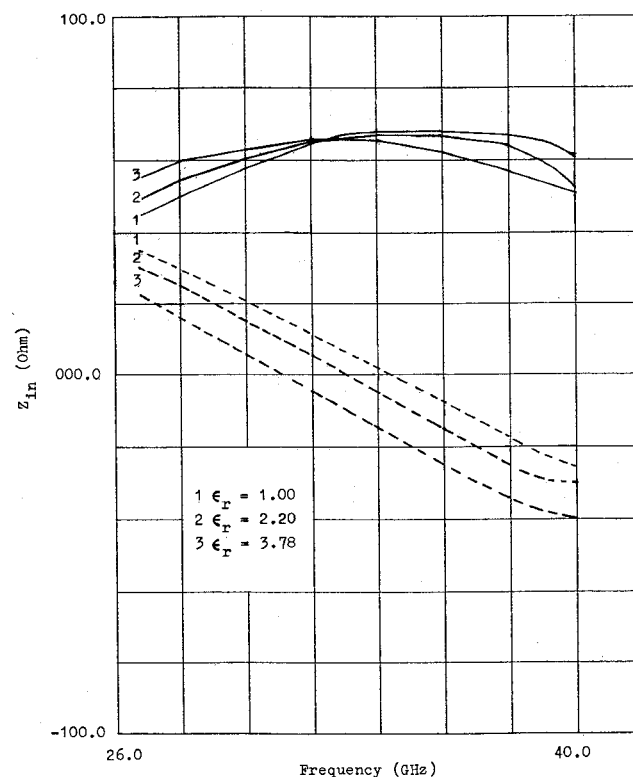


Fig. 3. Dominant mode impedance versus frequency as a function of  $\epsilon_r$ . *E*-plane transition with  $x_1 = 2.1$  mm,  $z_1 = 2.8$  mm,  $d_3 = 3.63$  mm, and  $w = 0.187$  mm. —  $\text{Re}(Z_{in})$ . ----  $\text{Im}(Z_{in})$ .

out frequencies. Data obtained by the integral equation technique using the current source are also presented in the same figure for comparison.

In this set of computations, all parameters are fixed at a constant value except for the relative dielectric constant. With the exception of  $d_3$  being 3.63 mm, all physical dimensions are the same as in the previous case. A 10-mil-thick substrate is used for the dielectric layer. Fig. 3 shows the dominant mode impedance of an *E*-plane waveguide to microstrip transition for the cases of air ( $\epsilon_r = 1.0$ ), Duroid ( $\epsilon_r = 2.2$ ), and quartz ( $\epsilon_r = 3.78$ ), which are used for the dielectric slab. The study shows that the reactance changes from inductive to capacitive at resonance. This response differs from the case of the total input reactance, in which a positive reactance slope is obtained. The input impedance lowers the resonant frequency for a higher dielectric constant. This behavior is expected because of higher  $\beta_{mn}$ . The characteristic of the input impedance of the *E*-plane waveguide to microstrip transition is then further studied for a number of cases with Duroid substrate. Fig. 4 shows the computed input impedance of the *E*-plane transition for four different cases. Here  $z_1$  is fixed to be constant, and  $x_1$  is varied from 1.6 to 2.2 mm in order to observe the frequency response of the input impedance. The resistive part of the input impedance increases almost linearly with the magnitude of  $x_1$  while the resonant frequency of the input reactance shifts toward the lower end of the waveguide band. Fig. 5 shows how the

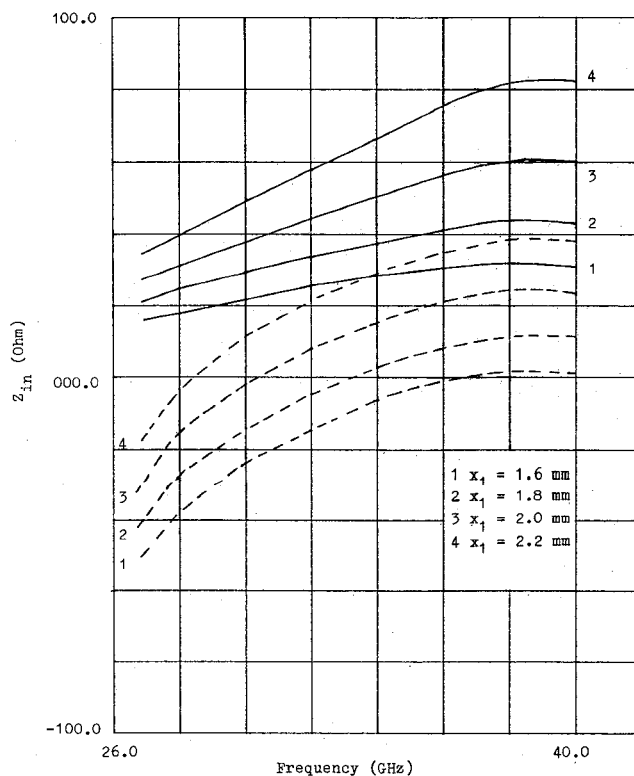


Fig. 4. Input impedance versus frequency as a function of  $x_1$ . *E*-plane transition with  $z_1 = 2.0$  mm,  $d_3 = 3.63$  mm,  $w = 0.187$  mm, and  $\epsilon_r = 2.2$ . —  $\text{Re}(Z_{in})$ . ----  $\text{Im}(Z_{in})$ .

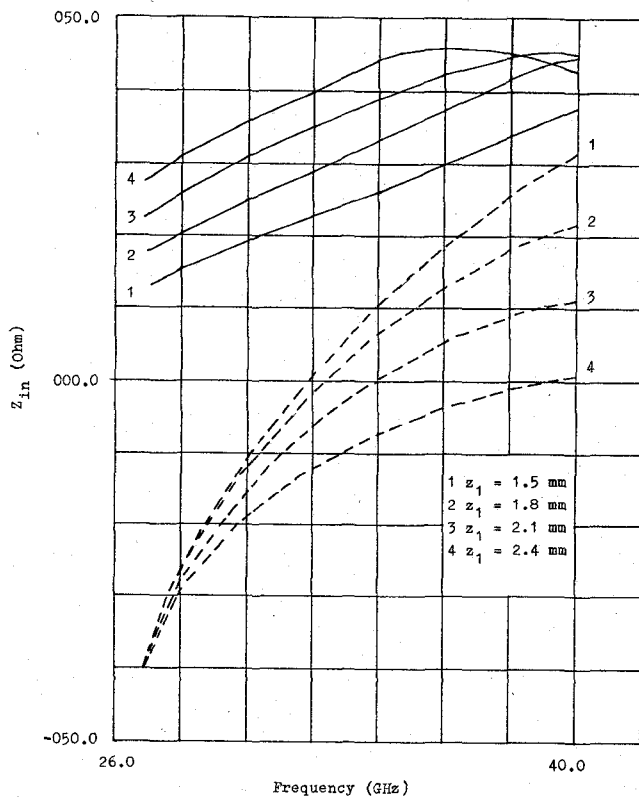


Fig. 5. Input impedance versus frequency as a function of  $z_1$ . *E*-plane transition with  $x_1 = 1.8$  mm,  $d_3 = 3.63$  mm,  $w = 0.187$  mm, and  $\epsilon_r = 2.2$ . —  $\text{Re}(Z_{in})$ . ----  $\text{Im}(Z_{in})$ .

input impedance changes with frequency as a function of the backshort location  $z_1$ . The quantity  $x_1$  is chosen to be 1.8 mm and  $w$  is also fixed at 0.187 mm. In these cases,  $z_1$  is varied from 1.5 mm to 2.4 mm and a family of curves is generated. As the backshort moves farther from the center of the microstrip probe, we observe that the frequency which indicates the maximum radiation band as the reactive part of the impedance lowers its saturation level. The input reactance is more sensitive to the variation of  $z_1$  in the upper half of the *Ka*-band.

In the experimental study, a chemical etching technique was used for fabricating the transitions on 10-mil-thick Duroid substrates. The printed circuit was then mounted on a general-purpose split block test fixture for RF evaluation. Fig. 6 shows the configuration of a *Ka*-band waveguide to microstrip transition embedded inside the test fixture. The exciting aperture is small and its effect on the input impedance is relatively insignificant. We used the reflection coefficient instead of directed  $Z_{in}$  measurement because of the difficulties involved in obtaining a *Ka*-band vector network analyzer and in developing a de-embedding technique to extract measured  $S$  parameters. The dimensions of the transition were obtained through the evaluation of (7).  $Z_0$  was chosen to be 70.0  $\Omega$ . Fig. 7 shows the calculated and typical measured input *VSWR* of an *E*-plane waveguide to microstrip transition when  $x_1 = 2.0$  mm,  $z_1 = 2.5$  mm,  $d_3 = 3.63$  mm,  $w = 0.187$  mm, and  $\epsilon_r = 2.2$  are used as the parameters. The data show that a

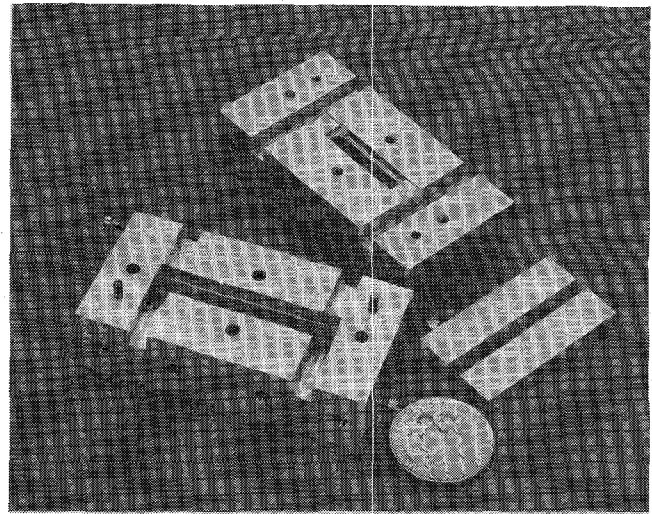


Fig. 6. *Ka*-band waveguide to microstrip transition circuit.

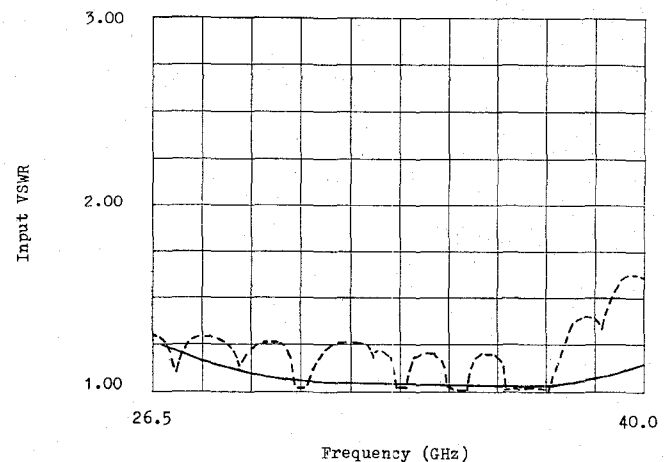


Fig. 7. Input *VSWR* versus frequency. *E*-plane waveguide to microstrip transition with  $x_1 = 2.0$  mm,  $z_1 = 2.5$  mm,  $d_3 = 3.63$  mm,  $w = 0.187$  mm, and  $\epsilon_r = 2.2$ . — Theoretical. ---- Experimental.

value of 1.28 or better was achieved over most of the waveguide band. Numerical results obtained by the spectral-domain technique in general agree reasonably well with the experimental data.

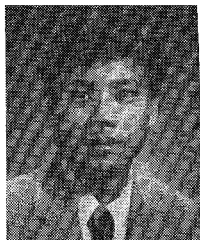
#### IV. CONCLUSION

The spectral-domain technique and a residue calculus theorem have been applied to the analysis of a waveguide excitation problem. The formulation utilizes a self-reaction concept to calculate the input impedance of the structure. The analysis takes into account the dielectric layer effect, which is important in high-frequency applications. Various cases are studied with respect to the probe length and the backshort location. The new formulation yields numerical results agreeing well with those computed using the integral equation technique and those measured at *Ka*-band frequencies.

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